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**Supporting Information for** 

Porous Nickel Electrodes with Controlled Texture for Hydrogen Evolution

Reaction and Sodium Borohydride Electrooxidation

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Notes

The authors declare no competing financial interest.

5 pages: page I - V

6 figures: figure S1-S6

1 table: table S1

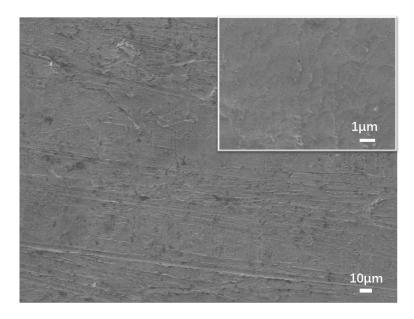
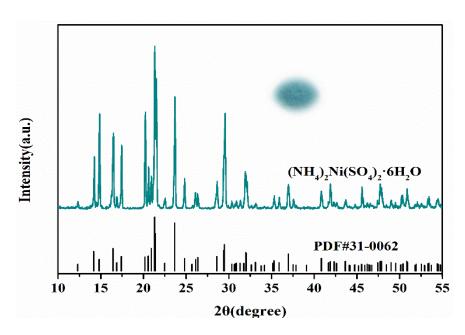
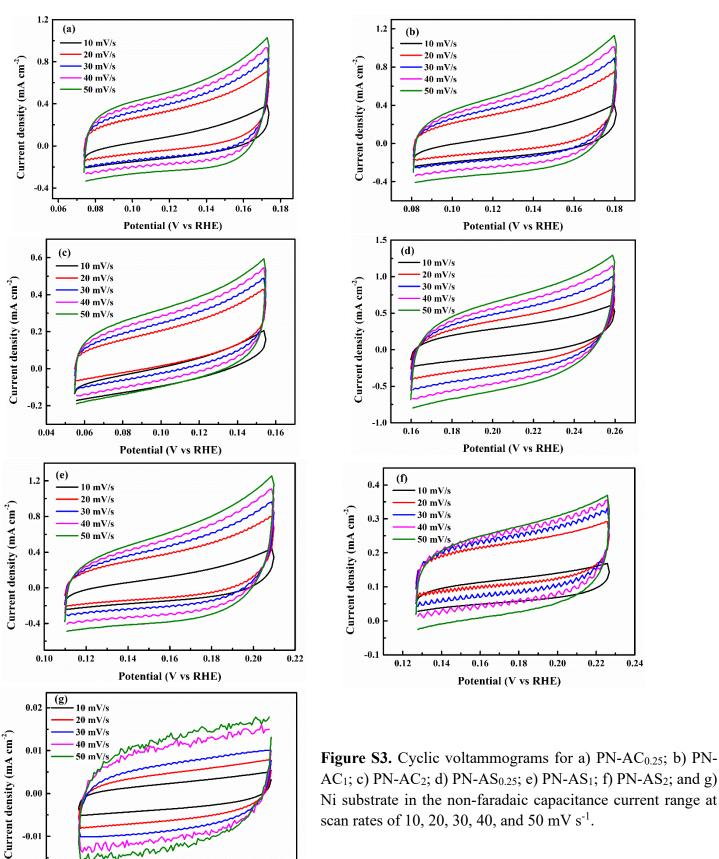


Figure S1. SEM image of the Ni substrate.



**Figure S2.** XRD pattern of the precipitates in solution when (NH<sub>4</sub>)<sub>2</sub>SO<sub>4</sub> concentration over 0.5M.



AC<sub>1</sub>; c) PN-AC<sub>2</sub>; d) PN-AS<sub>0.25</sub>; e) PN-AS<sub>1</sub>; f) PN-AS<sub>2</sub>; and g) Ni substrate in the non-faradaic capacitance current range at scan rates of 10, 20, 30, 40, and 50 mV s<sup>-1</sup>.

0.84

0.82

-0.01

-0.02

0.72

0.74

0.76

0.78

Potential (V vs RHE)

0.80

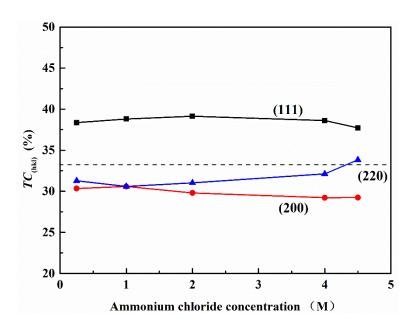
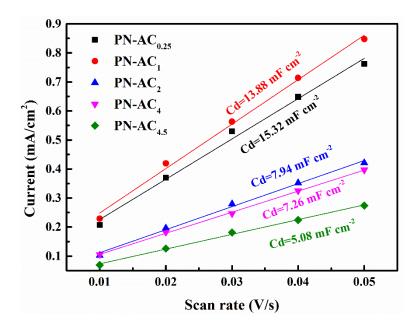
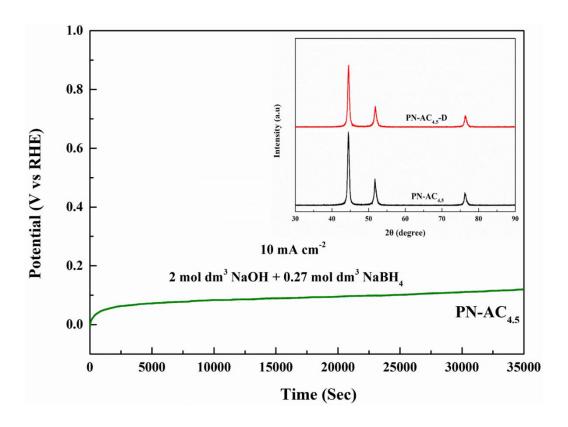


Figure S4. Relationship between texture of porous Ni electrodes and concentration of NH<sub>4</sub>Cl.



**Figure S5.** Corresponding capacitive currents at the specific potential vs Hg/HgO as a function of scan rate (10, 20, 30, 40, and 50 mV s<sup>-1</sup>).



**Figure S6.** Chronopotentiometry curves of NaBH<sub>4</sub> oxidation on PN-AC<sub>4.5</sub> at 25 °C in 0.27 M NaBH<sub>4</sub> + 2 M NaOH solution. Embedded: XRD patterns of PN-AC<sub>4.5</sub> and PN-AC<sub>4.5</sub>-D (PN-AC<sub>4.5</sub> after the long-stability test).

Table S1. The  $C_{dl}$  and ECSA of Ni electrodes.

	C <sub>dl</sub> (mF cm <sup>-2</sup> )	ECSA (cm <sup>2</sup> )
PN-AC <sub>0.25</sub>	13.88	555.2
$PN-AC_1$	15.32	612.8
$PN-AC_2$	7.94	317.6
$PN-AS_{0.25}$	21.01	840.4
$PN-AS_1$	18.06	722.4
PN-AS <sub>2</sub>	4.55	182
Ni substrate	0.49	19.6